

IN THE CLAIMS

This listing of claims replaces all prior versions and listings of the claims in the above-referenced application.

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1. (Currently Amended) A light-emitting device comprising:
a heterostructure of III-nitride materials comprising an active region having a peak emission wavelength, an n-layer, and a p-layer;
a p- and an n-electrode, the p-electrode being attached to the p-layer, the n-electrode being attached to the n-layer, wherein the p-electrode and n-electrode are attached to a same side of the light emitting device; and
a superstrate, having a refractive index greater than 1.8 a refractive index of sapphire, attached to the heterostructure.
2. (Original) A light-emitting device, as defined in claim 1, wherein the superstrate has an absorption coefficient less than 3 cm^{-1} at the peak emission wavelength.
3. (Original) A light-emitting device, as defined in claim 1, wherein the p-electrode has an absorption less than 25%.
4. (Original) A light-emitting device, as defined in claim 1, wherein at least one of the layers comprising the heterostructure is textured.
5. (Original) A light-emitting device, as defined in claim 1, wherein the superstrate is selected from a group that includes SiC, ZnO, YAG, ZnSe, ZnS, zirconia, diamond, and CdS.
6. (Original) A light-emitting device, as defined in claim 5, wherein the superstrate is SiC and has a resistivity greater than $0.5\text{ }\Omega\text{ cm}$.
7. (Original) A light-emitting device, as defined in claim 1, wherein at least one surface of the superstrate is roughened.

8. (Original) A light-emitting device, as defined in claim 1, wherein a top surface area of the superstrate is larger than a bottom surface area of the superstrate.

9. (Original) A light-emitting device, as defined in claim 1, wherein a portion of the p-electrode interposes portions of the n-electrode.

10. (Original) A light-emitting device, as defined in claim 1, wherein the p-electrode comprises Au/NiO_x/Al.

11. (Original) A light-emitting device, as defined in claim 1, wherein light is extracted from the active region through the superstrate.

12. (Original) A light-emitting device, as defined in claim 1, further comprising:
a submount;
an n-interconnect connecting the n-electrode to the submount; and
a p-interconnect connecting the p-electrode to the submount.

13. (Original) A light-emitting device, as defined in claim 12, wherein the n-interconnect and p-interconnect are selected from the group consisting of solder, elemental metals, metal alloys, semiconductor-metal alloys, thermally and electrically conductive pastes, thermally and electrically conductive compounds, epoxies, eutectic joints, Au stud-bumps, and solder bumps.

14. (Original) A light-emitting device, as defined in claim 12, further comprising:
a p-conductive interface disposed between the p-interconnect and the p-electrode; and
an n-conductive interface disposed between the n-interconnect and the n-electrode.

15. (Original) A light-emitting device, as defined in claim 14, wherein the p-conductive interface and the n-conductive interface comprise wettable metals.

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16. (Currently Amended) A light-emitting device, as defined in claim 14, wherein the lateral ~~cross~~ cross sectional area of the n-conductive interface and the p-conductive interface is at least 15% of an area of the p-electrode.

17. (Original) A light-emitting device, as defined in claim 14, further comprising a barrier layer disposed between the p-electrode and the p-conductive interface.

18. (Original) A light-emitting device, as defined in claim 17, wherein the barrier layer is selected from the group consisting of Ni, Cr, Cu, and Ti.

19. (Original) A light-emitting device, as defined in claim 12, wherein the submount comprises a material selected from the group consisting of Si, AlN, and BeO.

20. (Original) A light-emitting device, as defined in claim 12, wherein the submount has a thickness less than 250 μ m.

21. (New) A light-emitting device, as defined in claim 1, wherein the superstrate is SiC.

22. (New) A light-emitting device, as defined in claim 1, wherein the superstrate has an index of refraction greater than an index of refraction of at least one of the n-layer and the p-layer.
